

L Number	Hits	Search Text	DB	Time stamp
1	1243	(dry adj3 etching) adj10 (insulator or inslating or insulate or oxide) same substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/25 13:54
2	481	(expose or exposed or exposing) adj10 (insulat or insulating or insulator) same atmosphere	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/25 13:55
3	9	((dry adj3 etching) adj10 (insulator or inslating or insulate or oxide) same substrate) and ((expose or exposed or exposing) adj10 (insulat or insulating or insulator) same atmosphere)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/25 13:55

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	IS&R	L1	468	(438/151).CCLS.	USPAT	2002/11/25 15:27
2	IS&R	L3	262	(438/695).CCLS.	USPAT	2002/11/25 15:41
3	IS&R	L4	390	(438/149).CCLS.	USPAT	2002/11/25 15:48
4	IS&R	L7	323	(438/197).CCLS.	USPAT	2002/11/25 15:51
5	IS&R	L8	87	(438/142).CCLS.	USPAT	2002/11/25 16:05
6	IS&R	L9	321	(438/287).CCLS.	USPAT	2002/11/25 16:09